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PATENT

AF/1753
JPW

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of: John Commander, et al. Art Unit: 1753
Serial No.: 10/091,106
Filed: March 5, 2002
Confirmation No.: 5919
For: DEFECT REDUCTION IN ELECTRODEPOSITED
COPPER FOR SEMICONDUCTOR APPLICATIONS
Examiner: Edna Wong

July 27, 2005

AMENDMENT E AFTER FINAL

TO THE COMMISSIONER FOR PATENTS,

SIR/MADAM:

This responds to the Office action mailed May 27, 2005.

Please enter the following amendments and consider the following remarks.

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks begin on page 6 of this paper.

Conclusion begins on page 7 of this paper.

Ok to enter. 02/8/5/05